

IN THE UNITED STATES PATENT AND TRADEMARK OFFICE

#15/ Amatt B  
R. Tyson  
1/23/01

In re the Application of: Yasunori INOUE et al  
Serial No.: 09/228,148  
Filed: January 11, 1999



Group Art Unit: 2823

Examiner: K. Eaton

For: MANUFACTURING METHOD OF SEMICONDUCTOR DEVICE INCLUDING AN INSULATION FILM ON A CONDUCTIVE LAYER (As Amended)

AMENDMENT

Director of Patents and Trademarks  
Washington, D.C. 20231

January 11, 2001

Sir:

In response to the Office Action dated October 11, 2000, please amend the above-identified application as follows:

IN THE TITLE:

Please amend the title to read -- Manufacturing Method Of Semiconductor Device Including An Insulation Film On A Conductive Layer --.

IN THE CLAIMS:

Please amend claim 9 as follows:

Claim 9, line 7, change "a film" to -- an intrusion prevention film --.

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REMARKS

Claims 9 - 18 are pending. The title and claim 9 amended hereby.

The Examiner still has not acknowledged cancellation of claims 1-8 as shown in the application transmittal letter. Only claims 9 - 18 are pending.